BULLETIN OF THE POLISH ACADEMY OF SCIENCES TECHNICAL SCIENCES
DOI: 10.24425/bpasts.2021.137509

This article has been accepted for publication in a future issue of this journal, but has not been fully edited. Content may change prior to final publication.

Bandwidth and Power Enhancement in the MEMS Based Piezoelectric Energy Harvester using Magnetic Tip Mass

Enhanced power and bandwidth in PZEH with magnetic tipmass

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ABSTRACT: In this paper, the performance and frequency bandwidth of the piezoelectric energy harvester (PZEH) is improved by introducing two permanent magnets, which is attached to the proof mass of a dual beam structure. Both magnets are in the vicinity of each other and attached in such as a way to proof mass of a dual-beam, so that they create a magnetic field around each other. The generated magnetic field develops a repulsive force between the magnets, which improves not only electrical output but also enhances the bandwidth of harvester. The simple rectangular cantilever structure with and without magnetic tip mass has the frequency bandwidth of 4 Hz and 4.5 Hz respectively. The proposed structure generates a peak voltage of 20 V at a frequency of 114.51 Hz at an excitation acceleration of 1g (g=9.8 m/s²). The peak output power of a proposed structure is 12.2 µW. The operational frequency range of a proposed dual-beam cantilever with magnetic tip mass of 30 mT is from 102.51 Hz to 120.51 Hz i.e., 18 Hz. The operational frequency range of a dual-beam cantilever without magnetic tip mass is from 104.18 Hz to 118.18 Hz i.e., 14 Hz. There is an improvement of 22.22 % in the frequency bandwidth of proposed dual-beam cantilever with magnetic tip mass of 30 mT than the dual-beam without magnetic tip mass.

Key words: Vibration, Piezoelectric Energy harvester, Magnetic Tip mass, Bandwidth, Stress.

1. Introduction

The advancement in the field of VLSI and ever-increasing interest in the Internet of Things (IoT) leads to rapid advancement in the development of the miniaturized low power electronic devices. There are several barriers in the global implementation of IoT, such as the dependency on the conventional battery for the power supply. These batteries have a limited life-span. Thus, energy harvesting from the ambient energy source became an active research area. The energy harvesting from the vibration of the ambient nature is the most promising way to power these miniaturized low power electronic devices like wireless sensors nodes, biomedical devices, military equipment's etc. The vibration energy harvester (EH) converts vibration energy into the useable electric energy. Vibration energy can be converted into electrical energy using electrostatic [1][2], electromagnetic [3][4] and piezoelectric (PZ) mechanism [5-13]. The piezoelectric transducer is the most favored, as it has high energy density, easy integration in CMOS technology, high durability and it does not need any external voltage source [10]. There are many EH designs such as cantilever [5,6], clampedclamped beams [13], diaphragms [13], cymbal type structure [13], shell and stack type structures [13]. The cantilever structure is the most used structures as it has a higher average strain energy. The rectangular type cantilever structure is most easy to fabricate and implement. Apart from energy harvesting, the piezoelectric materials have been used in several different applications such as buckling [14], stability [14,15], vibration or loading capacity control [16], tactile sensing [17], etc.

The piezoelectric energy harvester (PZEH) has the ability to generate maximum output voltage and power at the resonant frequency. Even the slight change in an ambient frequency can drastically reduce the efficiency of a PZEH. Numerous researches are going on to eliminate this limitation. One of such method is the use of non-linearity in the EH design [18][19].

One of the methods to introduce non-linearity is the use of magnetic tip mass as a proof mass in the magnetic environment [19]. The relative alignment, position and arrangement of the magnet can introduce non-linearity in the system. There are several configurations to improve the efficiency and operating bandwidth of PZEH. The permanent magnet has been used in the

EH system to achieve monostable [20][21], bi-stable [22-24] or tri-stable state [25-28] and hence able to increase the operating frequency range. Challa et al. [19] designed EH of size 34 mm and tune the resonant frequency with the magnetic force by changing the relative position of the magnets. Zhou et al. [29] tries to achieve a penta-stable state by adjusting the position and orientation of permanent magnet and hence improve the efficiency. Tan et al. [30] tries to device a method to calculate magnetic force in the vibration and energy harvesting efficiency of the piezoelectric energy harvester. Zhu et al. [31] designed (13 x 5) mm² cantilever beam for the electromagnetic microgenerator. The resonant frequency of the cantilever has been tuned with the help of attractive force of axially aligned permanent magnet. Wei-jiun et al. [32] designed a 98 mm dual cantilever to enhance the bandwidth of the EH with permanent magnet on a dual cantilever. D. Guo et al. [33] also designed 12 cm long array of cantilevers to enhance the frequency bandwidth with the magnetic tip mass and increase the performance of EH.

This paper tries to use the concept of multi-beam structure along with the use of magnetic field intensity in EH system to achieve the bandwidth improvement. This paper introduces dual magnets in a dual cantilever system. One magnet is attached to the proof-mass of the inner beam and the other magnet is attached to the outer beam. Both magnets are attached in the vicinity of each other to create the magnetic field intensity and interact with each other. This orientation helps in the improvement of the frequency bandwidth of the EH.

2. ELECTRICAL ANALYSIS OF PIEZOELECTRIC CANTILEVER

A simplified cantilever plate structure consist of piezoelectric plate on the top of a substrate layer is considered, to develop the analytical model as shown in Fig. 1. The thickness of the substrate layer is t_S and that of the piezoelectric layer is t_P . The effect of electrode is neglected in the analytical model due to its small thickness.

In a PZ material, the external force on the PZ layer generates electric field and vice versa. When the PZ cantilever operates in 31 mode, which means that stress generates in the lateral direction (X direction or 3 direction) and an electric field in

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transverse direction (Z direction or 1 direction). So, the equations (1a) and (1b) show the PZ property and inverse PZ property [5-6].

$$S_1 = S_{11}^E \cdot T_1 + d_{\underline{3}1} \cdot E_3 \tag{1a}$$

$$D_3 = d_{31}.T_1 + \varepsilon_{33}^T.E_3 \tag{1b}$$

 $S_1 = S_{11}^E.T_1 + d_{31}.E_3$ (1a) $D_3 = d_{31}.T_1 + \varepsilon_{33}^T.E_3$ (1b) Where S_1 is mechanical strain generated in the PZ material and D_3 is the electric displacement in the PZ materials under given mechanical stress T_l and electric field E_3 . s_{11}^E is strain under zero or constant electric field, ε^T_{33} is the permittivity of the material under zero or constant stress and d_{31} is the PZ coefficient.

The substrate layer is the normal linear elastic material, so the stress applied (T_s) in the substrate layer is directly proportional to the resultant strain (S_s) as

$$T_s = Y_s S_s \tag{2}$$

 $T_s = Y_s S_s$ (2) But, in case of the PZ material, applied stress (T_p) not only induces strain (S_p) but also generates an electric filed (E). When the rectangular cantilever structure vibrates in the vertical direction, stress acts in the x, y and xy plane. So, the applied stress, strain and electric field in the PZ layer is related as in equations (3) (a, b, c) [5-6].

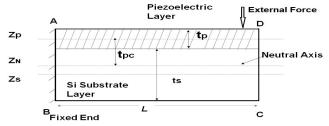


Fig. 1. Simplified version of the basic cantilever

$$T_{pxx} = \frac{Y_p}{1 - v^2} S_{pxx} + \frac{vY_p}{1 - v^2} S_{pyy} - d_{31} Y_p E$$
(3a)

$$T_{pyy} = \frac{Y_p}{1 - v^2} S_{pyy} + \frac{vY_p}{1 - v^2} S_{pxx} - d_{32} Y_p E$$
(3b)

$$T_{pxy} = G S_{pxx} - (d_{31} + d_{32}) Y_p E$$
(3c)

$$T_{pyy} = \frac{1}{V_p} S_{pyy} + \frac{1}{V_p} S_{pxx} - d_{32} Y_p E$$
 (3b)

$$T_{pxy} = GS_{pxx} - (d_{31} + d_{32})Y_pE$$
 (3c)

Where v is the poison ratio, G is the shear modulus and Y_p is the Young's Modulus of the PZ layer.

When the cantilever plate is subject to an external stress, it deflects from the mean position or neutral axis. This induces the bending strain in the layer away from the neutral axis. The equations 4 (a, b, c) shows the bending strain in the cantilever plates [5-6].

$$S_{pxx} = -(Z_N - Z) \frac{\partial^2 w(x,y,t)}{\partial x^2}$$
 (4a)

$$S_{pyy} = -(Z_N - Z) \frac{\partial^2 w(x, y, t)}{\partial x^2}$$
 (4b)

$$S_{pxy} = -2(Z_N - Z)\frac{\partial^2 w(x,y,t)}{\partial x \partial y}$$
 (4c)

ates [5-6]. $S_{pxx} = -(Z_N - Z) \frac{\partial^2 w(x,y,t)}{\partial x^2}$ (4a) $S_{pyy} = -(Z_N - Z) \frac{\partial^2 w(x,y,t)}{\partial y^2}$ (4b) $S_{pxy} = -2(Z_N - Z) \frac{\partial^2 w(x,y,t)}{\partial x \partial y}$ (4c) Where Z_N is the neutral plane and $(Z_N - Z) = t_{PC}$ is the stance from the neutral surface to the material point of interest, distance from the neutral surface to the material point of interest, w(x, y, t) is the transverse displacement of the cantilever structure.

Putting the value of strain from equation (4 (a, b, c)) into equation (3 (a, b, c)) [5-6], we have.

$$T_{pxx} = \frac{Y_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial x^2} \right) + \frac{vY_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial y^2} \right) - d_{31}Y_p E$$
(5a)

$$T_{pxx} = \frac{Y_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial y^2} \right) + \frac{vY_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial x^2} \right) - d_{32}Y_p E$$
(5b)

$$T_{pxy} = G\left(-2t_{PC}\frac{\partial^2 w(x,y,t)}{\partial x \partial y}\right) - (d_{31} + d_{32})Y_pE$$
 (5c)

The value of stress from equations (5 (a, b, c)) is substituted in equation (1b) to obtained the electric displacement in x, y and xy plane. The equation (6) shows the electric displacement due to stress in the x plane [5-6].

$$D_{zx} = d_{31} \left[\frac{Y_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial x^2} \right) + \frac{vY_p}{1 - v^2} \left(-t_{PC} \frac{\partial^2 w(x, y, t)}{\partial y^2} \right) - d_{31} Y_p E \right] + \mathcal{E}_{33}^T E$$
 (6)

The charge generated in the piezoelectric plate is given by equation (7) [5-6],

$$Q_{Total}(t) = d_{31} \int_{0}^{L} \int_{0}^{b} \left[\frac{Y_{p} t_{PC}}{1 - v^{2}} \left\{ \left(-\frac{\partial^{2} w(x, y, t)}{\partial x^{2}} \right) + v \left(-\frac{\partial^{2} w(x, y, t)}{\partial y^{2}} \right) \right\} + \left(\mathcal{E}_{33}^{T} - d_{31} Y_{p} \right) E \right] dx dy$$

$$= d_{31} \int_{0}^{L} \int_{0}^{b} \left[\frac{Y_{p} t_{PC}}{1 - v^{2}} \left\{ \left(-\frac{\partial^{2} w(x, y, t)}{\partial x^{2}} \right) + v \left(-\frac{\partial^{2} w(x, y, t)}{\partial y^{2}} \right) \right\} + \mathcal{E}_{31}^{s} \frac{V(t)}{t_{p}} dx dy$$

$$(7)$$

Where $(\mathcal{E}_{33}^T - d_{31}Y_p) = \mathcal{E}_{31}^s$, $E = \frac{V(t)}{t_p}$, t_p is a thickness of PZ layer, V(t) is the voltage generated in PZ layer.

Thus, total current generated in this plate is $I(t) = \frac{\partial Q_{Total}(t)}{\partial t}$. If R is the internal resistance of PZ plate, so according to the ohm's law the voltage generated in PZ plate is given by $V_1(t)$ = $I(t) \times R$, [5-6].

$$V_{1}(t) = -R \int_{0}^{L} \int_{0}^{b} d_{31} \left[\frac{Y_{p} t_{PC}}{1 - v^{2}} \left\{ \left(\frac{\partial^{2} w(x, y, t)}{\partial x^{2} \partial t} \right) + v \left(\frac{\partial^{2} w(x, y, t)}{\partial y^{2} \partial t} \right) \right\} - \frac{\varepsilon_{31}^{s}}{t_{p}} \frac{\partial V(t)}{\partial t} dx dy$$
(8)

Similarly, the voltage generated in a PZ layer due to the stress in y and xy plane can be evaluated as [5-6].

$$V_{2}(t) = -R \int_{0}^{L} \int_{0}^{b} d_{32} \left[\frac{Y_{p} t_{PC}}{1 - v^{2}} \left\{ \left(\frac{\partial^{2} w(x, y, t)}{\partial x^{2} \partial t} \right) + v \left(\frac{\partial^{2} w(x, y, t)}{\partial y^{2} \partial t} \right) \right\} - \frac{\varepsilon_{32}^{s}}{t_{p}} \frac{\partial V(t)}{\partial t} \right] dx dy$$

$$(9)$$

$$V_{3}(t) = -R \int_{0}^{L} \int_{0}^{b} (d_{31} + d_{32}) \left[Gt_{PC} \left(\frac{\partial^{2} w(x, y, t)}{\partial x \partial y \partial t} \right) - \frac{(\mathcal{E}_{31}^{s} + \mathcal{E}_{32}^{s})}{t_{p}} \frac{\partial V(t)}{\partial t} \right] dx dy$$

$$(10)$$

The total voltage generated across the PZ layer of the cantilever as in equation (11) [5-6].

$$V_4(t) = V_1(t) + V_2(t) + V_3(t)$$
(11)

So, from the above discussion (equations (7), (8), (9), (10) and (11)), it can be concluded that the electric voltage develop across the PZ layer depends on the stress distribution on the cantilever beam. So, when the all the other design parameter is same then the cantilever structure with a higher stress distribution gives higher voltage than the others. The introduction of the magnetic field in the PZ cantilever system with the help of the magnetic

tip mass will increase the stress districtution and hence improve the performance of the PZEH.

MECHANICAL MODELLING OF PZEH WITH MAGNET TIP MASS

The PZEH with permanent magnet attached to the proof mass which is axially aligned with the fixed magnet. Kirchhoff plate theory with additional magnetic force is used to model the system [5,6]. The nonlinear restoring force is produced by the magnetic force in the PZEH.

The mechanical deviation of cantilever plate in perpendicular direction can be expressed as equation (12a or 12b) [5][6][34].

$$D_{r}\left(\frac{\partial^{4}w(x,y,t)}{\partial x^{4}}+2\frac{\partial^{4}w(x,y,t)}{\partial x^{2}\partial y^{2}}+\frac{\partial^{4}w(x,y,t)}{\partial y^{4}}\right)+\rho t_{p}\frac{\partial^{2}w(x,y,t)}{\partial t^{2}}=f\left(x,y,t\right)_{m}\tag{12a}$$

or,
$$D_r \nabla^4 w(x, y, t) + \rho t_p \frac{\partial^2 w(x, y, t)}{\partial t^2} = f(x, y, t)_m$$
 (12b)
Where, ∇^4 is the biharmonic operator and is given in equation

(13), w(x, y, t) is the vertical displacement of the plate, ρ is the density, D_r is the flexural rigidity which is given in equation (14). $f(x,y,t)_m$ is the magnetic force between the magnets in the system at the any deflection w(x, y, t), is given by equation (15) [5][6][34].

$$\nabla^4 = \nabla^2 \nabla^2 = \frac{\partial^4}{\partial x^4} + 2 \frac{\partial^4}{\partial x^2 \partial y^2} + \frac{\partial^4}{\partial y^4}$$
 (13)

$$D_r = \frac{Yt^3}{12(1-v^2)} \tag{14}$$

$$\nabla^{4} = \nabla^{2} \nabla^{2} = \frac{\partial^{4}}{\partial x^{4}} + 2 \frac{\partial^{4}}{\partial x^{2} \partial y^{2}} + \frac{\partial^{4}}{\partial y^{4}}$$

$$D_{r} = \frac{rt^{3}}{12(1-v^{2})}$$

$$f(x, y, t)_{m} = -\frac{3\mu_{0} m_{1} m_{2}}{2\pi (D+w(x, y, t))^{4}}$$
(15)

Where m_1 and m_2 are the magnetic dipole which is given as $m_i = \frac{2BV_v}{\mu_0}$, i = 1,2. $\mu_0 (= 4\pi \times 10^{-7} \text{ H/m})$ is the permeability of the air and two magnets are D distance apart and V_v is the volume of the magnets.

There will be the repulsive force when both magnets are of same magnetic polarization and attractive in nature when the magnets are of opposite magnetic polarization.

When there is no magnetic force acting in the cantilever system then the $f(x, y, t)_m$ is taken as zero in equation (12). This is the case of free vibration of a cantilever plate [5][6][34] as

$$D_r \nabla^4 w(x, y, t) + \rho t_p \frac{\partial^2 w(x, y, t)}{\partial t^2} = 0$$
 (16)

The length and width of the rectangular plate is L and b, so the boundary limit along the length varies from x = 0 to L and along the width is y = 0 to b. When the external magnetic force (f(x,y,t)) will be considered then the solution of displacement of the rectangular cantilever i.e., equation (12) will be considered as [5][6][34].

$$D_r \nabla^4 w(x, y, t) + \rho t_p \frac{\partial^2 w(x, y, t)}{\partial t^2} = -\frac{3\mu_0 m_1 m_2}{2\pi (D + w(x, y, t))^4}$$
(17)

According to the vertical displacement of the plate we have,

$$w(x, y, t) = \sum_{m=1}^{\infty} \sum_{n=1}^{\infty} w_{mn}(x, y) T_{mn}(t)$$
 (18)

$$w(x, y, t) = \sum_{m=1}^{\infty} \sum_{n=1}^{\infty} w_{mn}(x, y) T_{mn}(t)$$
 (18)
Where, $w_{mn}(x, y) = B_{1mn} \sin \frac{m\pi x}{L} \sin \frac{n\pi y}{b}$; $m, n = 1, 2$.. (19)

The normalization condition that the normal nodes will satisfy is given as [5][6][34],

$$\int_{0}^{L} \int_{0}^{b} \rho t_{p} \, w_{mn}^{2} dx dy = 1 \tag{20}$$

 $\int_0^L \int_0^b \rho t_p \, w_{mn}^2 dx dy = 1 \tag{20}$ Which yields $B_{1mn} = \frac{2}{\sqrt{\rho t_p L b}}$. By using normalization condition in equation (20) and substituting it into equation (12), we obtained the equation of the governing the generalized coordinates $T_{mn}(t)$ as [5][6][34],

$$\frac{\partial^2 T_{mn}(t)}{\partial t^2} + \omega_{mn}^2 T_{mn}(t) = N_{mn}(t); \quad m, n = 1,2 \dots$$
 (21)

Where $N_{mn}(t)$ is the generalized force and the natural frequency ω_{mn} is given by [5][6][34],

$$N_{mn}(t) = \int_0^L \int_0^b w_{mn}(x, y) f(x, y, t)_m dx dy$$
 (22)

$$\omega_{mn} = \pi^2 \left(\frac{D_r}{\rho t_p}\right)^{1/2} \left[\left(\frac{m}{L}\right)^2 + \left(\frac{n}{b}\right)^2 \right]; \quad m, n = 1, 2 \dots$$
 (23)

[5][6][34],

$$T_{mn}(t) = T_{mn}(0)\cos\omega_{mn}t + \frac{1}{\omega_{mn}}\frac{\partial T_{mn}(t)}{\partial t}\sin\omega_{mn}t + \frac{1}{\omega_{mn}}\frac{\partial T_{mn}(t)}{\partial t}\sin\omega_{mn}t$$

$$\frac{1}{\omega_{mn}} \int_0^t N_{mn}(\tau) \sin \omega_{mn}(t-\tau) d\tau \tag{24}$$

The final solution of the rectangular plate vibration under external force is given by equation (25) [5][6][34].

$$w(x,y,t) = \sum_{m=1}^{\infty} \sum_{n=1}^{\infty} \frac{T_{mn}(0)}{\partial t} \sin \frac{m\pi x}{L} \sin \frac{n\pi y}{b} \cos[\omega_{mn}t] + \sum_{m=1}^{\infty} \sum_{n=1}^{\infty} \frac{\partial T_{mn}(0)}{\partial t} \frac{1}{\omega_{mn}} \sin \frac{m\pi x}{L} \sin \frac{n\pi y}{b} \sin[\omega_{mn}t] + \sum_{m=1}^{\infty} \sum_{n=1}^{\infty} \frac{1}{\omega_{mn}} \sin \frac{m\pi x}{L} \sin \frac{n\pi y}{b} \int_{0}^{t} T_{mn}(\tau) \sin[\omega_{mn}(t-\tau)] d\tau$$

$$\sum_{m=1}^{\infty} \sum_{n=1}^{\infty} \frac{1}{\omega_{mn}} \sin \frac{m\pi x}{L} \sin \frac{n\pi y}{b} \int_{0}^{t} T_{mn}(\tau) \sin \left[\omega_{mn}(t-\tau)\right] d\tau$$
(25)

Thus, it can be observed that the deflection of the end mass of the vibrating dual beam cantilever structure depends on the magnetic force (from equations (22), (24) and (25)). Hence the magnetic effect influences the vibration of the cantilever structure.

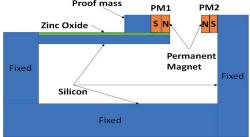


Fig. 2. Single rectangular cantilever beam with magnetic tip mass

4. DESIGN OF THE CANTILEVER STRUCTURE

4.1. Design of the single beam structure

The rectangular cantilever structure is designed with silicon as the substrate and zinc oxide as the PZ layer. The proof mass is at the tip of the free end of the cantilever consists of Si and permanent magnet (PM1), which helps to reduce the resonant frequency [5] as shown in Fig. 2. Another fixed magnet (PM2) is placed axially in the vicinity of the first magnet to create repulsive magnetic force [4]. The permanent magnet can act as a spring which produces non-linearity in the system. Table 1 and Table 2 complies all the dimension and properties of the materials used in designing of the cantilever plate. The magnetic

field intensity of the magnets used in the design of the simple rectangular structure is 5 mT. Both the magnets are 500 μ m apart. The COMSOL Multiphysics 5.3a is used to design the cantilever structure. The structure is meshed as the normal meshing techniques. The solid mechanics and electrostatics physics are used to obtained the mechanical and electrical characterization of the designed cantilever structure. The resonant frequency of the simple single rectangular cantilever structure is 95.5 Hz and that of the simple single rectangular cantilever with magnetic tip mass structure is 95 Hz, which is in agreement with the above discussion.

Before moving to the design of the dual beam structure, we first try to verify the effect of the magnetic field intensity on the stress distribution. For that, we have taken the designed simple rectangular cantilever of dimensions as shown in Fig. 2 and in table 1. The stationary study is employed on the designed cantilever structure to verify the effect of magnetic field intensity on the stress distribution. First stationary study is employed with fixed load of 1g (=9.8m/s²) only, then gradually the magnetic field intensity is introduced in the system to study its effect. The Fig. 3 shows the stress distribution along the arc length of the cantilever structure. It can be observed from the Fig. 3 that the stress distribution increases with the increase in the magnetic field intensity which is in agreement with the above discussed mathematical analysis.

4.2. Design of the dual beam structure

The rectangular shaped dual beam EH is designed to improve the bandwidth of the EH. The cantilever has the Si as substrate and ZnO as the PZ material. The proof mass is attached at the free end of the dual beam structure to reduce the resonant frequency. The permanent magnet is attached to each of the proof mass, such that they create the magnetic repulsive force around each other. Fig. 4 shows the arrangement of proof mass with permanent magnet. The magnetic field intensity of the magnet used in the dual beam structure is same as that of the single beam cantilever structure. The length of the inner beam (L2) and outer beam and (L1) is 4200 μm and 5000 μm respectively. The width of the arm of the outer beam (W3) connected to the fixed end is 500 µm and arm at the free end (W4) is 600 μ m. The width of the inner beam (W2) is 1000 μ m. The overall width of the dual beam (W1) is $2500 \mu m$. The total thickness of the dual cantilever beam is $14 \mu m$. The thickness of the Si substrate and ZnO are 12 μm and 2 μm respectively. The ZnO is distributed uniformly throughout the cantilever surface. The dimension of the proof mass connected to the inner beam (IPM) is 1000 x 1000 x 850 μm^3 , which consists of Si and permanent magnet (PM3). The length of the Si and permanent magnet is 800 µm and 200 µm, while width and thickness remain same. The proof mass of outer beam (OPM) is also consisting of Si and permanent magnet (PM4). The net dimension of the proof mass of the outer beam is 600 x 1000 x 850 µm³. The length of the Si layer is 400 µm and that of the permanent magnet is 200 um while width and thickness remain same. The gap between inner and outer beam is 250 µm and the distance between the two magnets is 200 µm. The perforation is introduced at the

proper position in the inner and outer beam to reduce the resonant frequency and brings their resonant frequency closer to each other [5]. The length (L₄) and width (W₄) of the perforation in the outer arm are 800 μm and 100 μm , respectively, whereas length (L₃) and width (W₃) of perforation of the inner arm is 1000 μm and 400 μm , respectively. The properties and the complete dimension of the materials used in the design of the dual beam is listed in the Table 2 and Table 3 respectively. The first two eigen frequency of the dual beam with the magnetic tip mass and without magnetic tip mass are 107.51 and 114.51 Hz.

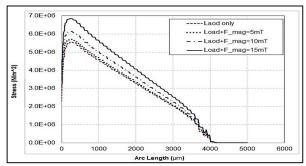


Fig. 3. Variation of stress along arc length with magnetic field intensity

Table 1. The geometry of different materials used in the single beam cantilever

	Si	ZnO	PROOF MASS		PM2
			Si	PM1	
Length (µm)	5000	5000	800	200	200
Width (µm)	1000	1000	1000	1000	1000
Thickness (µm)	12	2	850	850	850

Table 2. Property of the materials used in the cantilever beam [5,8,9]

Property	MATERIALS		
	Si	ZnO	Permanent Magnet
Young's Modulus (GPa)	170	210	0.1
Poisson ratio	0.29	0.33	0.29
Density (kg/m ³)	2329	5680	7500

Γable 3. Dimension of the dual beam

rable 5. Dimension of the data beam								
	Inner arm		Outer arm		IPM		OPM	
	Si	ZnO	Si	ZnO	Si	PM3	Si	PM4
Length(µm)	L1=	-4200	L1=	=5000	800	200	400	200
Width(µm)	W2:	=1000	W3=500, W4=600		′ 1 1000		1000	
Thickness(µm)	12	2	12	2	8	50	8	50

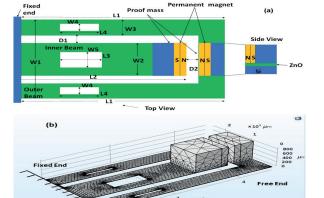


Fig. 4. (a) Top View dual beam structure with perforation (b) 3D view of meshed dual beam structure with perforation

5. MECHANICAL OUTPUT OF THE STRUCTURE

The electrical output of the PZEH depends on the average stress distribution in the cantilever structure, as shown by equations (1(b)), (6) and (7). Fig. 5 shows the comparison between the stress distribution of different cantilever structures at their respective resonant frequency. The stress distribution of dual beam is plotted to varying values of magnetic field intensity as shown in Fig. 5. The stress distribution is highest in the dual beam cantilever structure with magnetic tip mass at 30 mT magnetic field intensity at its resonant frequency. It can be concluded by Fig. 5 that the stress distribution within the cantilever increases with the increase in the magnetic intensity of the tip mass.

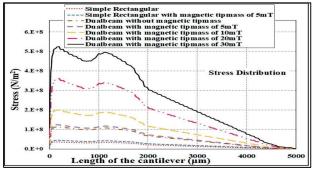


Fig. 5. Stress in different cantilever beams

The stress distribution in the cantilever beam increases when the magnetic intensity of the permanent magnet increases. The maximum stress developed in the cantilever beam should be less than Young's Modulus of the materials used in the design of the cantilever. The elastic nature in the materials and mechanical strength of the cantilever will be compromised, if the stress distribution within the cantilever will be higher than Young's Modulus. Fig. 5 shows the stress distribution of all the cantilevers, suggesting that all the cantilever have sufficient mechanical strength.

5. ELECTRICAL OUTPUT ANALYSIS OF THE CANTILEVER STRUCTURES

5.1 Output Voltage analysis of cantilever structures

The PZ based energy harvester generates the maximum output voltage and output power at the resonant frequency which is given by equation (23). Therefore, a time domain analysis is carried out at a respective resonant frequency of all the rectangular cantilever structures with and without magnetic tip mass and for dual cantilever beams with and without magnetic tip mass in COMSOL Multiphysics. The transient analysis gives the time dependent voltage. A sinusoidal acceleration of 1g (g = 9.8 ms⁻²) is applied to all the structure at their respective resonant frequency. Fig. 6 shows the time varying output voltage of all the cantilever structures at their resonant frequency.

The peak output voltage of simple rectangular cantilever beam is 18.4 V at its resonant frequency, i.e., 96 Hz. The rectangular cantilever with 5 mT magnetic tip mass is 21.2 V at its respective resonant frequency of 95.5 Hz. It can be observed that with the introduction of magnetic effect in the cantilever structure, the output voltage increases. The paper's main focus is to improve the bandwidth so the higher magnetic field intensity is only used in the dual beam cantilever structure.

Similarly, transient analysis on the dual beam is carried out by applying a sinusoidal acceleration of 1g (g is the acceleration due to gravity) and varying the frequency of the cantilever structure. It is observed that the peak output voltage of the simple dual beam cantilever structure is 12 V at the frequency of 115.18 Hz, and that of the dual beam with magnetic tip mass of 5mT is 14 V at the frequency of 115 Hz. The peak output voltage of dual beam with magnetic tip mass of 10 mT, 20 mT, and 30 mT is16.4 V, 18.5 V, and 20 V at their respective resonant frequency of 114.81 Hz, 114.61 Hz, and 114.31 Hz.

5.2 Output Power analysis of the cantilever structure

The maximum output power is generated by PZEH when the resonant frequency of the structure matches the ambient frequency. The other necessary condition is the value of optimum load resistance which is same as that of the internal resistance [1][5][6][7]. The internal resistance of the simple rectangular cantilever will be same as that of the rectangular cantilever with a magnetic tip mass since both the configuration has the same dimension. Similarly, the internal resistance of all dual beam cantilever structures will be the same irrespective of magnetic field intensity. The electrical equivalent of single beam piezoelectric cantilever is represented by Fig. 7.

The inner beam and outer beam of the dual beam are connected in a parallel configuration. So, the electrical equivalent of the coupled plate structure can also be represented as a parallel combination of two current sources, two capacitors, and two resistors, as shown in Fig. 8.

The equivalent capacitor of the equivalent circuit is sum of the individual capacitors. The reciprocal of equivalent resistance is equal to the sum of the reciprocal of individual resistance. Since there is no direct method to find the internal resistance, it will be calculated indirectly. The PZEH will generate maximum power when the load resistance is equal to the internal resistance of PZEH. This load resistance is called optimum load resistance. The optimum load resistance is calculated by simulating the PZEH at the resonant frequency by varying the load resistance. The graph of the output power of different cantilever structures at varying load resistance is plotted. The position at which the maximum output power is achieved for the given load resistance will give the optimum load. Fig. 9 shows the graph between the variation of the output power with the load resistance. It may be observed from the graph that the optimum load for the simple rectangular and rectangular with magnetic tip mass has an optimum load of 2 M Ω and the optimum load for the inner arm and outer arm of the dual beam are 1.6 M Ω and 1.3 M Ω . Hence the equivalent internal resistance of the dual beam is $0.72 \text{ M}\Omega$.

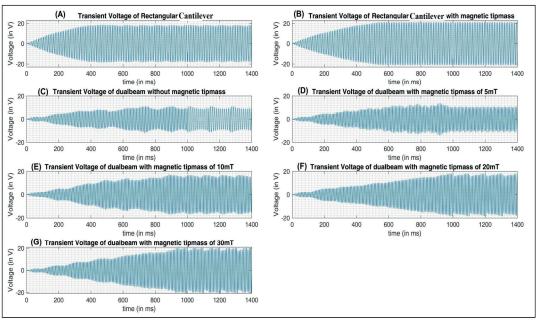


Fig. 6. Transient Voltage of (a) Simple Rectangular (b) Rectangular with magnetic tip mass (c) Dual Beam without magnetic tip mass (d) Dual Beam with magnetic tip mass of 5mT (e) Dual Beam with magnetic tip mass of 10mT (f) Dual Beam with magnetic tip mass of 20mT (g) Dual Beam with magnetic tip mass of 30mT

The maximum power is calculated at this optimum load resistance. The average output power is calculated by calculating the ratio of the average square of the transient voltage obtained at the particular frequency with the optimum resistance of the cantilever structure. Fig. 10 shows the variation of the average output power with the frequency for all the different structures in the same graph.

The output power and output voltage of the dual beam have two peaks at 107.51 Hz and 114.51 Hz. There is a dip in the output voltage and output power at 110.51 Hz. This dip in the voltage and power may be due to the out-of-phase motion of the dual beam. The peak voltage and power at frequencies 107.51 Hz and 114.51 Hz may be due to the in-phase motion of the dual beam.

Since the stress distribution increases with the increase in the magnetic field intensity in the cantilever, as shown in Fig. 5. So, the output power of the cantilever structures increases with the increase in the magnetic field intensity, as shown in Fig. 10. Also, it can be observed from Fig. 5 that there is an increase in stress distribution along the length of the cantilever when the magnetic field intensity increases. So, there may be a possibility that the strength of the cantilever can be compromised when the magnetic intensity of the magnet increases abruptly. So, there should be the optimum magnetic field strength that can be applied while designing the EH system.

The combined output voltage plot of all cantilever structures is plotted together in the same frequency scale. This plot gives the working bandwidth (or frequency range) of all the cantilever structures. The output voltage of all cantilever structures is shown in Fig. 11.

The bandwidth of operation is assumed as the frequency range at which the output voltage is greater than 2 V as most of the low power devices can efficiently run with a 2 V power supply. The bandwidth of all the structures discussed here is tabulated in Table 4. It can be observed that the single cantilever

structures, i.e., simple rectangular and simple rectangular with 5 mT magnetic intensity, have the bandwidth of 4 Hz (94 Hz-98 Hz) and 4.5 Hz (93 Hz- 97.5 Hz), respectively. The operating bandwidth of the dual-beam structure without magnetic tip mass has a bandwidth of 14 Hz (104.18 Hz- 118.18 Hz). The introduction of the magnetic tip mass in the dual beam structure increased the operating frequency range of the cantilever. The bandwidth of the dual beam with a magnetic tip mass of 5mT, 10 mT, 20 mT, and 30 mT are 14 Hz, 15 Hz, 16 Hz, 17 Hz, and 18 Hz, respectively. It must be noted that in the dual beam structure, each beam must have a different resonant frequency. The resonant frequency of each beam in the dual beam must be close so that the structures can produce voltage over the wide frequency range. So, if the proper cantilever beam is not selected while designing the dual beam then wideband energy harvester will not be achieved. Finally, the proposed work is compared with the available literature in Table 5. It can be observed from the table that the present work has been able to achieve higher or comparable bandwidth and shows an improvement in the performance with EH with a smaller dimension than the reported literature.

7. CONCLUSION

In this paper, the effect of magnetism in the piezoelectric cantilever beam with magnetic tip mass has been discussed. The article shows an improvement not only in terms of the electrical output, which includes the output voltage and output power of the harvester but also it helps in improving the operating frequency range of the harvester. In this paper, a single beam rectangular structure with and without magnetic tip mass is simulated, which enhances the harvester's electrical output. The dual beam structure is simulated with and without the magnetic tip mass in the COMSOL Multiphysics, which also improves the output voltage and power. The dual beam structure also shows an improvement in the frequency bandwidth with the

introduction of the magnetic field intensity. The increase in the magnetic field intensity improves the output voltage and power of the dual beam structures. There is a significant improvement in the frequency bandwidth of the dual beam structures compared to the single beam rectangular structures. The operational frequency bandwidth of the dual beam cantilever with a magnetic tip mass of 30 mT is 18 Hz as compared to the simple rectangular cantilever with or without the magnetic tip mass, which has the operational frequency bandwidth of 4.5 Hz and 4 Hz. The operating frequency range of the proposed dual beam cantilever with magnetic tip mass is from 102.51 Hz to 120.51 Hz. The proposed dual beam's output power and output voltage with a magnetic tip mass of 30 mT is 12.2 μW and 20 V, respectively.

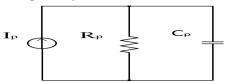


Fig. 7. Electrical equivalent model of a PZ Cantilever Plate

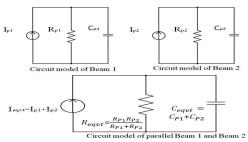


Fig. 8. Electrical equivalent circuit model for coupled dual beam structure

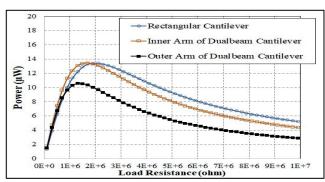


Fig. 9. Variation of Output Power with Load Resistance

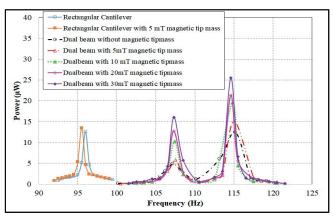


Fig. 10. Variation of output power with Frequency for all cantilever structures

Table 4. Bandwidth of all the structure

Structures	Bandwidth	Peak Voltage (V)	Average Power (µW)	
Simple Rectangular Cantilever	4 Hz (94-98 Hz)	18.4	12.614	
Rectangular Cantilever with magnetic tip mass of 5mT	4.5 Hz (93- 97.5 Hz)	21.2	13.52	
Dual beam without magnetic tip mass	14 Hz (104.18- 118.18 Hz)	12	12.42	
Dual beam with magnetic tip mass of 5mT	15 Hz (103.51- 118.51 Hz)	14	15.12	
Dual beam with magnetic tip mass of 10 mT	16 Hz (103.51- 119.51 Hz)	16.4	19.58	
Dual beam with magnetic tip mass of 20 mT	17 Hz (103.51- 120.51 Hz)	18.5	21.4	
Dual beam with magnetic tip mass of 30 mT	18 Hz (102.51- 120.51 Hz)	20	25.5	

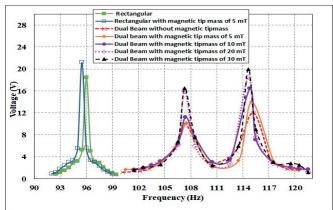


Fig. 11. Variation of output voltage with Frequency for all cantilever structures

Table 5. Comparison of the proposed work with the existing literature

Ref (year)	Dimension	Bandwidth	Electrical output
[19] Challa	Beam- 34x20x0.6	10 Hz (22	Power - 240-280
et.al. (2008)	mm ³	-32 Hz)	μW
[31] Zhu	Beam- 13x5x0.12	30.4 Hz	Power - 61.6-156.6
et.al (2010)	mm ³	(67.6 - 98	μW
		Hz)	
[32] W. Su	Length 98 mm,	3.8 Hz (10	Power – 1.8 mW
et.al. (2014)	width 20 mm,	- 13.8 Hz)	
	thickness 0.531 mm		
[33] Guo	Beam 1- 120x20x2	14 Hz (28-	Beam 1- Voltage -
et.al.	mm ³ Beam 2-	42 Hz)	24.84 V, power
(2016)	120x20x1 mm ³		81.97 mW/g ² ; Beam
			2 Voltage - 18.36V,
			Power -44.78
			mW/g^2
This work	5x2.5x0.014 mm ³	18 Hz	Voltage – 20 V,
		(102.51-	Power 12.20 μW
		120.51	
		Hz).	

This article uses the concept of a multi-beam structure using the magnetic field strength in the EH system to improve the bandwidth. The use of an efficient electrode design can further enhance the efficiency of EH. Another way to change the

orientation and position of a permanent magnet to enhance the bandwidth further.

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